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PTO/SB/08A (08-00)

Substitute for form 1449B/PTO  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (use as many sheets as necessary)				<i>Complete if Known</i>	
				Application Number	09/850,195
				Filing Date	May 8, 2001
				First Named Inventor	THEKKATH
				Group Art Unit	2113
Examiner Name	Baderman, Scott T.				
Sheet	1	of	2	Attorney Docket Number	MTEC-008/00US

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS				
Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.		T <sup>2</sup>
MC	D1	F. Chow et al., "Engineering a RISC Compiler System," <i>IEEE COMP-CON</i> , March 1986, pp. 132-137.		
MC	D2	FALOUTSOS, CHRISTOS et al., "Description and Performance Analysis of Signature File Methods for Office Filing", <i>ACM Transactions on Office Information Systems</i> , (July 1987), 5:3:237-257.		
MC	D3	Susan J. EGGERS, et al., "Techniques for Efficient Inline Tracing on a Shared-Memory Multiprocessor," University of Washington, 1990 <i>ACM</i> , pp. 37-47.		
MC	D4	M.D. Smith, "Tracing with Pixie," <i>Technical Report CSL-TR-91-497</i> , Stanford University, Computer Systems Laboratory, November 1991, pp. 1-29.		
MC	D5	ATOM Reference Manual, <i>Digital Equipment Corporation</i> , Massachusetts, December 1993, pp. 1-32.		
MC	D6	A. Srivastava et al., "ATOM: A System for Building Customized Program Analysis Tools," <i>WRL, Research Report 94/2</i> , Digital Equipment Corporation, Massachusetts, March 1994, pp. 1-23.		
MC	D7	ATOM User Manual, Digital Equipment Corporation, March 1994, pp. 1-28.		
MC	D8	B. Cmelik et al., "Shade: A Fast Instruction-Set Simulator for Execution Profiling," <i>Proceedings of the 1994 ACM SIGMETRICS Conference</i> , SIGMETRICS, California, May 1994, pp. 128-137.		
MC	D9	Richard A. UHLIG, et al., "Trace-Driven Memory Simulation: A Survey," Intel Microcomputer Research Lab; University of Michigan, <i>ACM Computing Surveys</i> , Vol. 29, No. 2, June 1997, pp. 128-170.		
MC	D10	Eric ROTENBERG, et al., "Trace Processors," University of Wisconsin, 1997 <i>IEEE Service Center</i> , 12 pp.		
MC	D11	E.N. ELNOZAHY, "Address Trace Compression Through Loop Detection and Reduction," ©1999 <i>ACM 1-58113-083</i> , pp. 214, 215.		
MC	D12	MIPS Technologies; "MIPS64™ 5K™ Processor Core Family Integrator's Guide;" [Document No. MD00106]; ©1999-2001 <i>MIPS Technologies, Inc.</i> ; Rev. 02.00; January 15, 2001; pp. I-VIII, 1-75.		
MC	D13	Darren JONES, "Opal Coprocessor Interface," <i>MIP Proprietary/Confidential</i> , June 4, 1999, pp. 1-18.		
MC	D14	Darren JONES, <i>MIPSS64™ 5K™ Processor Cores User's Manual</i> , Rev. 1.0, July 4, 1999, pp. 6-1 to 6-26.		

re	D15	MIPSS64™ 5K™ Processor Cores User's Manual, Rev. 1.0.1., 1999, pp. 247-276.	
re	D16	Embedded Trace Macrocell, (Rev. 1) Specification, (2000).	
re	D17	MIPS Technologies; "MIPS64™ 5K™ Processor Core Integrator's Guide;" [Document No. MD00056]; MIPS Technologies, Inc.; Rev. 1.2; August 11, 2000; pp. 1-11, 1-82.	
re	D18	MIPS Technologies; "Core Processor Interface Specification;" [Document No. MD00068]; MIPS Technologies, Inc.; Rev. 1.11; March 30, 2001; pp. 1-26.	

Examiner Signature		Date Considered	1/5/06
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U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No. <sup>1</sup>	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY
		Number	Kind Code <sup>2</sup> (if known)		
rc	P1	5,084,814		Vaglica et al.	01/28/1992
	P2	6,032,268		Swoboda et al.	09/29/2000
	P3	6,687,865		Dervisoglu et al.	02/23/2004
	P4	6,754,804		Hudepohl et al.	06/22/2004
	P5	09/751,747		Hudepohl et al.	12/29/2000
	P6	09/751,748		Hudepohl et al.	12/29/2000
	P7	09/844,671		Thekkath et al.	04/30/2001
	P8	<del>09/844,669</del> 09/844,669		Thekkath	04/30/2001
	P9	09/894,832		Thekkath et al.	06/29/2001
	P10	09/844,668		Thekkath et al.	04/30/2001
	P11	09/844,672		Thekkath	04/30/2001
	P12	09/844,673		Thekkath	04/30/2001
	P13	09/844,271		Thekkath	04/30/2001
	P14	09/894,831		Treue et al.	06/29/2001
	P15	09/894,830		Treue et al.	06/29/2001
rc	P16	09/844,670		Thekkath	04/30/2001

FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No. <sup>1</sup>	Foreign Patent Document			Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY
		Office <sup>3</sup>	Number <sup>4</sup>	Kind Code <sup>5</sup> (if known)		

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